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Epoxy Chemistry Research update 27. April 2021

Pascal Studer Laboratory for Soft Materials



Current research topics

- Characterisation of Araldite CY192-1 / HY918 system
- Phenoxy resins
 - Linear polymers which potentially exhibit high fracture toughness at cryogenic temperatures
- High Tg-epoxy (Tg > 140°C)
 - For engineering a specific epoxy composite with UHMWPE
- High K_{1c}-epoxy by adding reactive diluents to high Tg epoxy

Araldite CY192-1 / HY918

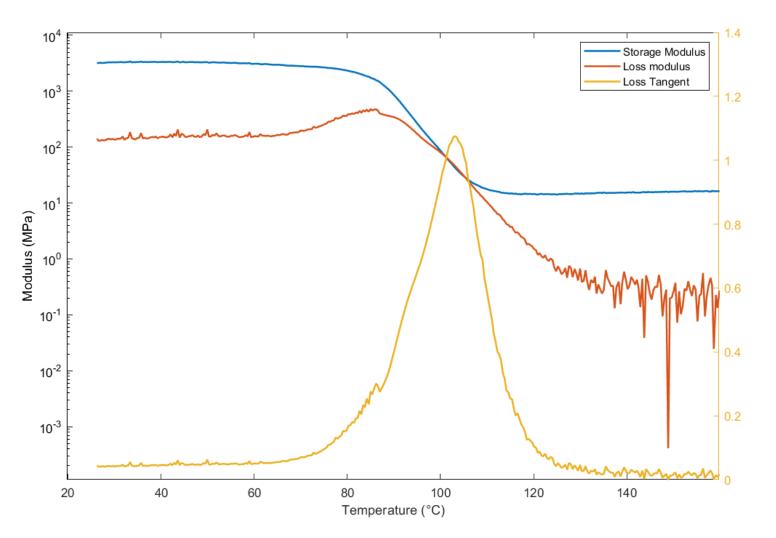
- T_g: 89°C by DSC (inflection point)
- Fracture toughness: KIc
 - Significant increase at lower temperature, but still low compared to MY750!

RT	LN2
0.87	2.79
0.92	2.07
0.86	2.57



Araldite CY192-1 / HY918

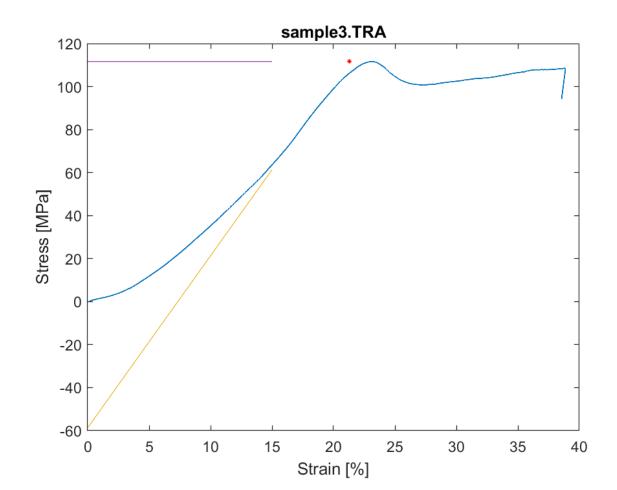
- DMTA
 - 3-point bending, 1 Hz, 0.02% strain, 2°C/min
 - E' at 25°C: 3.2 GPa
 - Tg from max(tanδ): 103°C
- Flexural bending:
 - E' at 25°C: 3.06 GPa



Araldite CY192-1 / HY918

- Compression testing at 0.1s⁻¹
 - Brittle fracture in LN2
 - At RT:

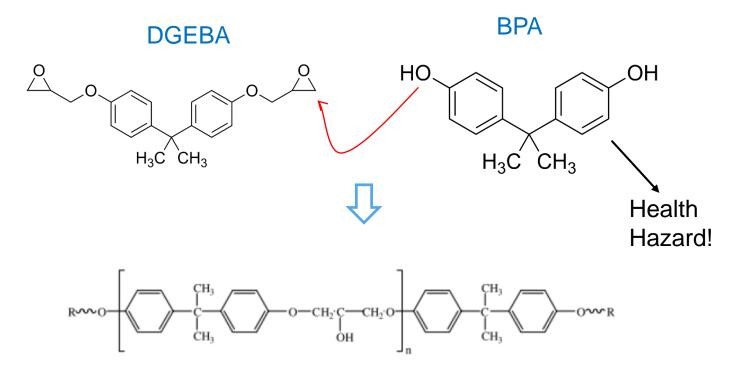
Yield strain	Yield stress
(%)	(Mpa)
22.1	116.3
21.3	111.6
20.3	109.0



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Phenoxy resins

- Phenoxy resins are mainly linear
 - Increased fracture toughness at cryogenic temperatures



D: DGEBA + BPA E: DGEBiphenyl + BPA F: Novolac + BPA

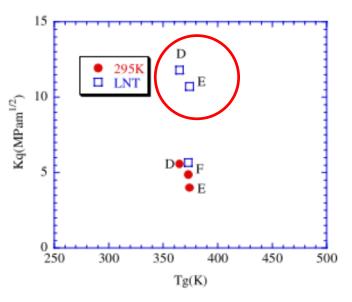
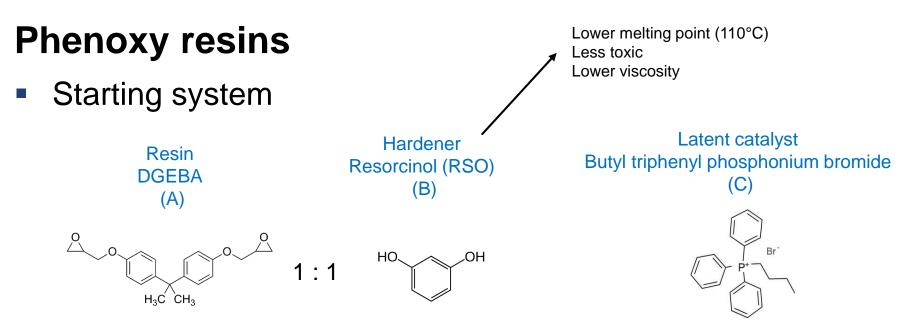
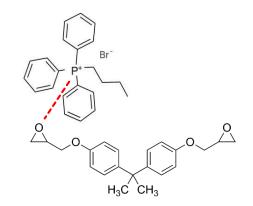


Fig. 9. Relationship between K_q and T_g .

Epoxies for cryogenic use: Ueki et al., Cryogenics, 2004, DOI: 10.1016/j.cryogenics.2004.07.002



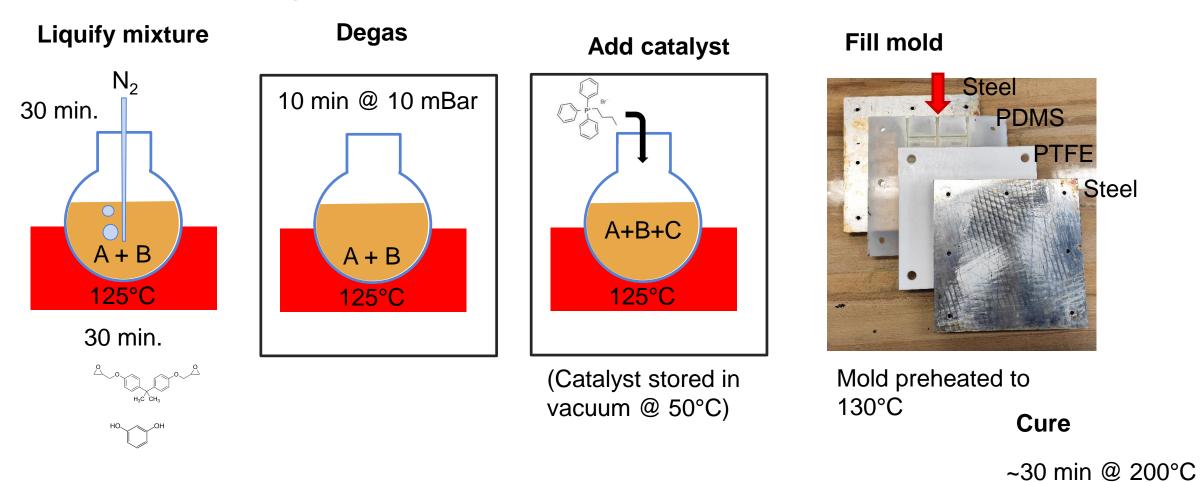
- Example: 14.72g DGEBA, 4.74g RSO, ~6.8mg catalyst
- A and B: equimolar amount



Example synthesis: Shih et al., J. appl. Polym. Sci., 1999, ISSN: 00218995

Phenoxy resins

Current processing method

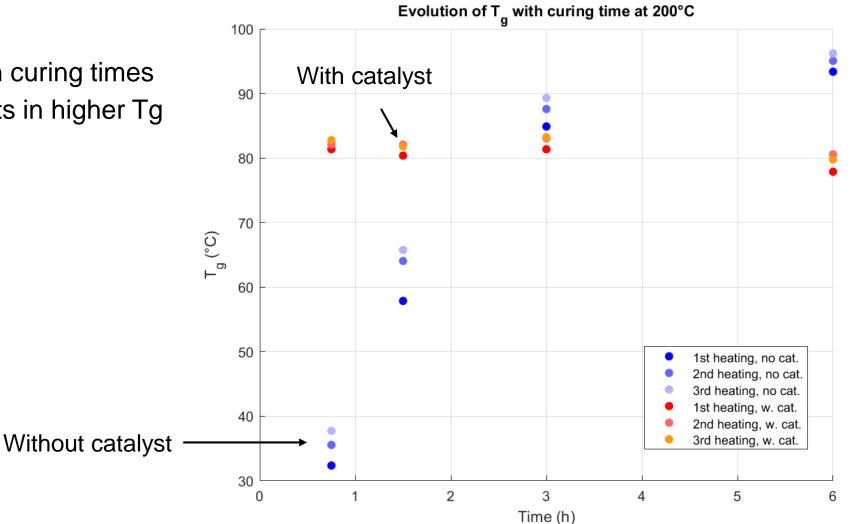


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Example synthesis: Shih et al., J. appl. Polym. Sci., 1999, ISSN: 00218995

Phenoxy resins

- Results
 - Effect of catalyst on curing times
 - More catalyst results in higher Tg



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Phenoxy resins

Problem: Bubbles in the samples

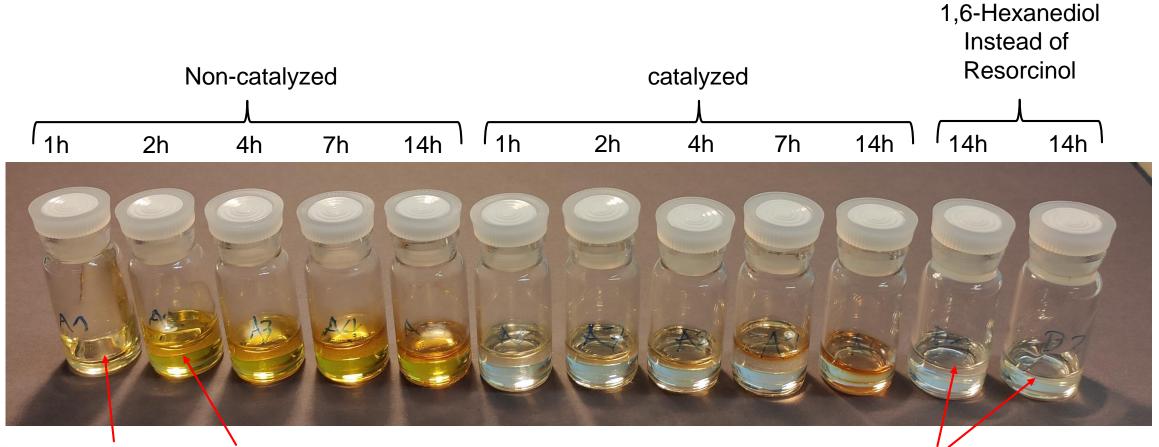
- Water bubbles due to condensation of hydroxy-groups?
 - No, mass loss during curing insignificant
 - 4.0 Mass. ‰ without catalyst
 - 1.9 Mass. ‰ with catalyst
- Catalyst interaction with PDMS mold?
 - No, samples cured without catalyst also have bubbles!
 - Without catalyst: Longer curing time (~6h)
- Residual gas in the mixture?
 - Probably no
 - When degassing at 10mbar, first strong bubbling, then less and less
 - Going to lower pressures, mixture begins boiling
 - Resorcinol: Vapour pressure P=3.35 mBar @ 125°C (Antoine Equation)
- Trying a lower curing temperature...DMATL.



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Phenoxy resins

- $T_{Cure} = 165^{\circ}C$
- Samples for DSC study



liquid Pascal Studer

27.04.2021

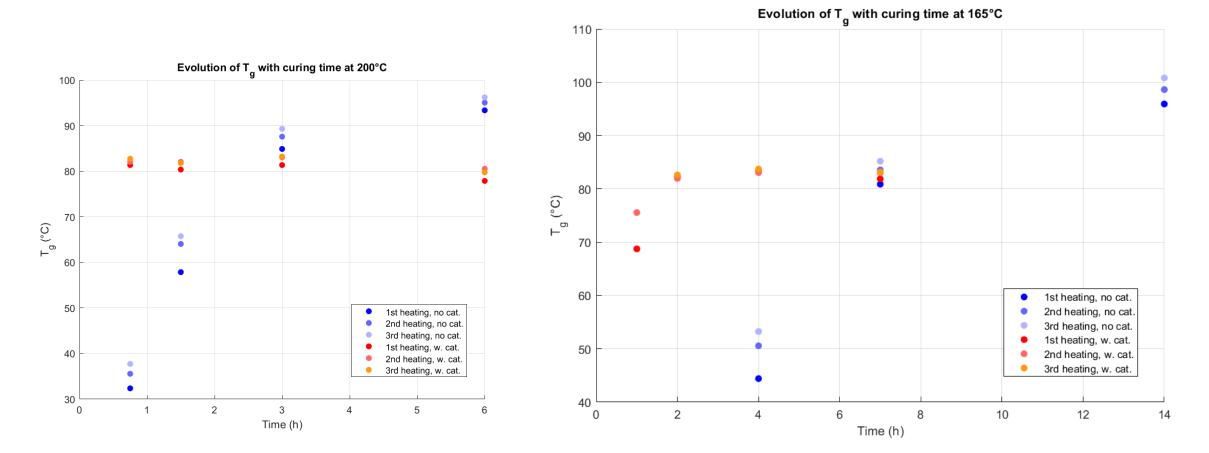
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Phenoxy resins

■ T_{Cure} = 200°C

$T_{Cure} = 165^{\circ}C \rightarrow \text{almost no bubbles!}$



Phenoxy resins – characterization

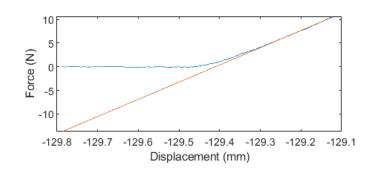
- Single-etch notch bend specimens
 - W x H x L ~ 5mm x 9mm x 40mm
 - Tested with 200N loadcell @ Zwick
- Calculated KIc values (MPa*m^{0.5})

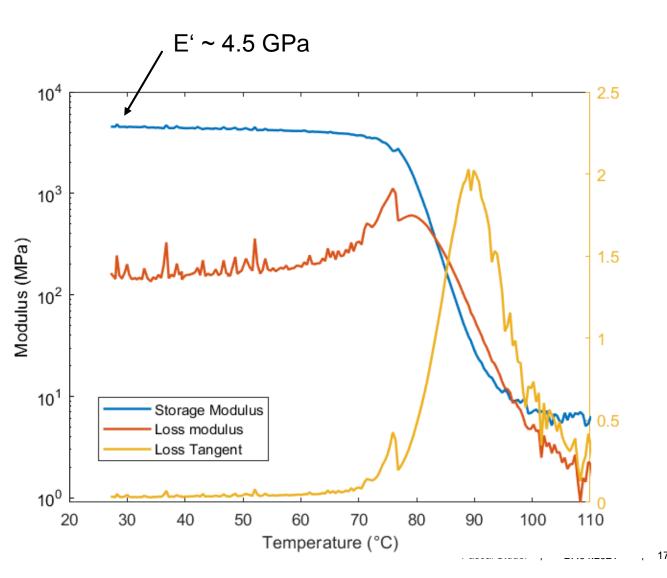
RT	LN2
1.09	1.62
1.23	1.55
0.86	1.46
1.08	1.46
0.63	



Phenoxy resins – characterization

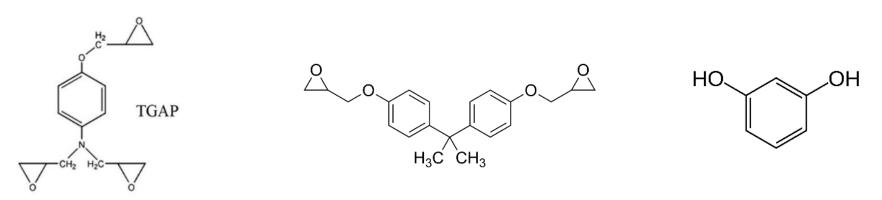
- Bending specimens
 - W x H x L ~ 4mm x 3mm x 40mm
- DMTA with ARES-G2
 - 1 Hz
 - 0.005 % strain amp.
 - Temperature sweep @ 3°C/min
- Flexural modulus with Zwick
 - E' @ RT: 3.4 Gpa
 - W x H x L ~ 5mm x 5mm x 60mm

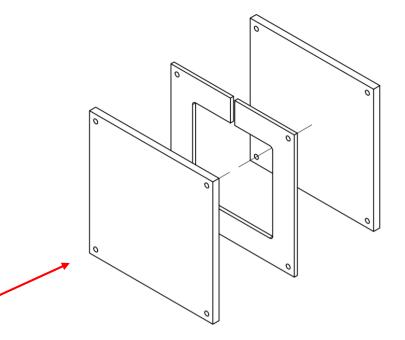




Phenoxy resins – Continuation

- Lower Tg (~80°C) compared to samples cured in glass vial (~100°C)
- Modulus seems dependent on sample dimensions
- Still some bubbles, especially in thin samples
- Dimension tolerances of samples could be better
- Fracture toughness much lower than expected
- \rightarrow move away from silicone mold
- → make PTFE mold for plates for water-jet cutting, design in progress

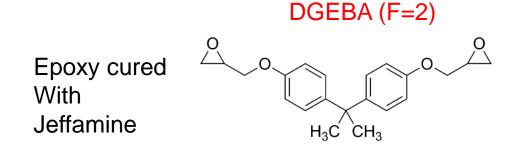




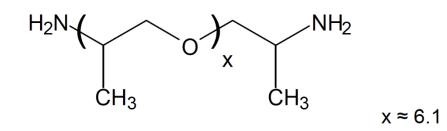
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Phenoxy resins – Continuation

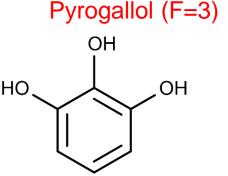
- Advantage of phenoxy chemistry: Long curing time
- Imitate the network structure of tough resins
 - Use long difunctional monomers in network
 - Or slightly crosslink the linear network using TGAP (trifunctional)



Jeffamine (F=4)





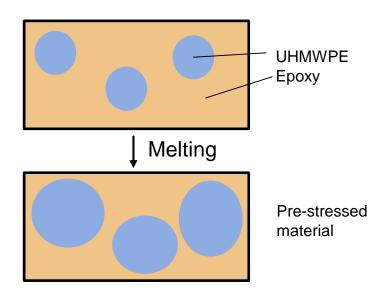


Poly(propylene glycol) diglycidyl ether (F=2)

 CH_3

High T_g epoxy composite

Idea



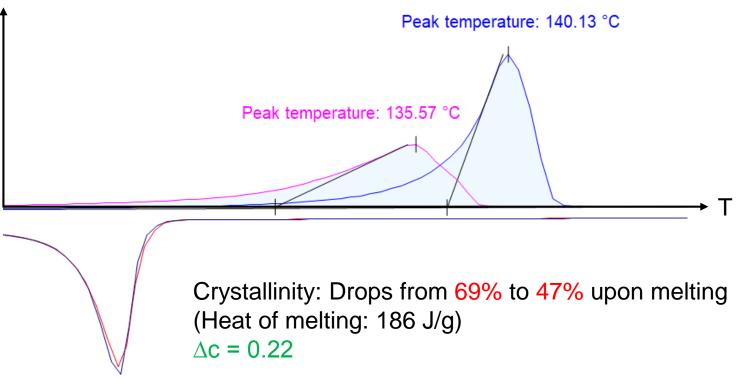
Materials

- UHMWPE particles:
 - Mitsui Mipelon PM-200
 - Particle size ~10 microns
 - Melting point: 140°C
- High Tg epoxy
 - To be synthesized

High T_g epoxy composite

DSC of the UHMWPE powder

Q (endo up)



Shrinkage of epoxy: About 1% over 200K

Calculations

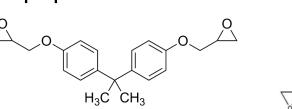
- $p_c = 1.004 \text{ g/cm3}$
- $p_a = 0.853 \text{ g/cm}3$
- $\Delta c = 0.22$

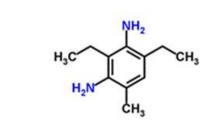
 $\left(\left(\frac{p_c}{p_a}-1\right)\Delta c+1\right)^{\frac{1}{3}} = 1.0128$

- → 1.28% linear expansion (melting)
- $\alpha_{PE} = 108^{*}10^{-6} \text{ K}^{-1}$ - $\Delta T = 200 \text{ K}$

High T_a epoxy composite

- Composition from reference paper
 - DGEBA 100 pHr
 - TGAP 20 pHr
 - DETDA 34 pHr

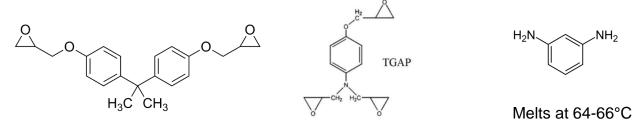




 NH_2

TGAP

- Miscible at 40°C, curing cycle: 100°C 60 min, 150°C 90 min., 177°C 120 min.
- Tg: 200°C
- Materials I have in the lab
 - DGEBA
 - TGAP
 - m-phenylenediamine



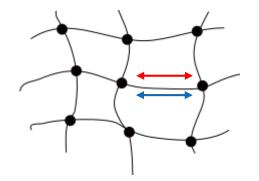


References Jin-Woo et al., J. Appl. Polym. Sci., 2012, DOI: 10.1002/app.38040

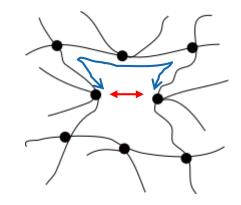
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High Klc epoxy

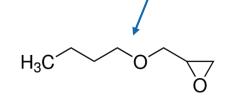
- Important research findings
 - The toughness increases with increasing topological distance between crosslinks



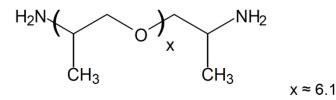
Euclidean distance Topological distance



Approach: Reactive diluents, RESD, long-chain monomers such as Jeffamine



Reaction in presence of solvent, Then drying

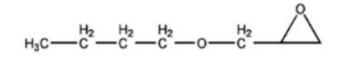


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References RESD; network topology: Sharifi et al., J. Mater. Chem., 2014, DOI: 10.1039/c4ta03051f Reactive diluents: Jin-Woo et al., J. Appl. Polym. Sci., 2012, DOI: 10.1002/app.38040

Idea for a epoxy with high fracture toughness

- Start from a known high Tg resin: DGEBA, TGAP and DETDA
 - Change network structure with reactive diluents, e.g. butylglycidylether, BGE
 - Increases toughness of network





PGE

Lowers Tg

Does not affect Tg much

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First result

- Materials:
 - Araldite MY750 DGEBA, ~5.3 equiv/kg
 - TGAP: Tri-glycidyl p-aminophenol
 - BGE: Butyl glycidyl ether
 - MPD: M-phenylene diamine
- Procedure

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- Degassing at 75°C 10 min 10 mbar
- Curing: 100°C 60 min, 150°C 90 min, 177°C 120 min
- Samples feel tough, testing to be done

Wrinkles on samples, from PTFE foil, PTFE foil only wrinkled where sample was

→ Order thicker PTFE foil (this was 170g/m2)
→ Which kind available at PSI?

